IN THE CLAIMS

1. (currently amended) A glass composition comprising 59-66 mol % SiO_2, ~~14.5~~15.0-18.0 mol % Al_2O_3, 8.5-12.0 mol % Na_2O, 2.5-6.5 mol % K_2O, 2.5-9.0 mol % CaO, 0.0-3.0 mol % MgO, 0.0-3.0 mol % SrO, 0.0-3.0 mol % BaO, ~~and~~ 0.0-5.0 mol % MgO+SrO+BaO, and 0.0-0.45 mol % B_2O_3.

2. (original) The glass composition of claim 1 having a liquidus temperature of 1100°C or less.

3. (original) The glass composition of claim 1 having a viscosity at a liquidus temperature of at least 10^5 poise.

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4. (original) The glass composition of claim 1 having a viscosity at a liquidus temperature in excess of 4×10^5 poise.

5. (original) The glass composition of claim 1 having a linear coefficient of thermal expansion of 80 to 95 x 10^{-7}/°C over a temperature range of 25 to 300°C.

6. . (currently amended) The glass composition of claim 5 having a linear coefficient of thermal expansion of 87 to 92 x 10^{-7}/°C over a temperature range of 25 to 300°C.

7. (original) The glass composition of claim 1 having a strain point greater than 580°C.

8. (original) The glass composition of claim 7 having a strain point of at least 640°C.

9. (currently amended) The glass composition of claim 1 further comprising at least one oxide selected from the group consisting of ~~B_2O_3~~, P_2O_5, Li_2O, Y_2O_3, La_2O_3, and ZnO in a total amount not exceeding 5 mol %.

10. (original) The glass composition of claim 1 wherein a molar ratio of Na_2O to K_2O is approximately 1.0.

11. (original) The glass composition of claim 1 wherein a molar ratio of Na_2O to K_2O is in a range from 1.2 to 3.0.

12. (original) The glass composition of claim 1 comprising 60-65 mol % SiO_2, 15.5-17.0 mol % Al_2O_3, 9.5-11.0 mol % Na_2O, 3.5-5.5 mol % K_2O, 3.5-8.0 mol % CaO, 0.0-2.0 mol % MgO, 0.0-2.0 mol % SrO, 0.0-2.0 mol % BaO, and 0.0-3.0 mol % MgO+SrO+BaO.

13. (currently amended) The glass composition of claim 1 further comprising at least one oxide selected from the group consisting of ~~B_2O_3;~~ P_2O_5, Li_2O, Y_2O_3, La_2O_3, and ZnO in a total amount not exceeding 3 mol %.

14. (currently amended) A glass composition comprising 59-66 mol % SiO_2, ~~14.5~~15.0-18.0 % Al_2O_3, 8.5-12.0 mol % Na_2O, 2.5-6.5 mol % K_2O, 2.5-9.0 mol % CaO, 0.0-3.0 mol % MgO, 0.0-3.0 mol % SrO, ~~and~~ 0.0-3.0 mol % BaO, and 0.0-0.45 mol % B_2O_3.

15. (original) The glass composition of claim 14, wherein MgO+SrO+BaO are present in a total amount of 0-5 mol %.

16. (original) The glass composition of claim 14, comprising 60-65 mol % SiO_2, 15.5-17.0 mol % Al_2O_3, 9.5-11.0 mol % Na_2O, 3.5-5.5 mol % K_2O, 3.5-8.0 mol % CaO, 0.0-2.0 mol % MgO, 0.0-2.0 mol % SrO, and 0.0-2.0 mol % BaO.

17. (original) The glass composition of claim 16, wherein MgO+SrO+BaO are present in a total amount of 0-3 mol %.

18. (currently amended) A glass composition comprising 59-66 mol % SiO_2, 14.5-18.0 mol % Al_2O_3, 8.5-12.0 mol % Na_2O, 2.5-6.5 mol % K_2O, 2.5-9.0 mol % CaO, 0.0-3.0 mol % MgO, 0.0-3.0 mol % SrO, 0.0-3.0 mol % BaO, ~~and~~ 0-5 mol % MgO+SrO+BaO, and 0.0-0.45 mol % B_2O_3, the glass composition exhibiting a strain point of at least 640°C and a linear coefficient of thermal expansion of 80 to 95 x 10^{-7}/°C over a temperature range of 25 to 300°C.

19. (original) The glass composition of claim 18 having a liquidus temperature of 1100°C or less.

20. (original) The glass composition of claim 18 having a viscosity at a liquidus temperature of at least 10^5 poise.

21. (original) The glass composition of claim 18 having a viscosity at a liquidus temperature in excess of 4×10^5 poise.

22. (original) The glass composition of claim 18 comprising 60-65 mol % SiO_2, 15.5-17.0 mol % Al_2O_3, 9.5-11.0 mol % Na_2O, 3.5-5.5 mol % K_2O, 3.5-8.0 mol % CaO, 0.0-2.0 mol % MgO, 0.0-2.0 mol % SrO, 0.0-2.0 mol % BaO, and 0.0-3.0 mol % MgO+SrO+BaO.

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23. (currently amended) A glass substrate for an electronic display device, comprising 59-66 mol % SiO_2, ~~14.5~~15.0-18.0 mol % Al_2O_3, 8.5-12.0 mol % Na_2O, 2.5-6.5 mol % K_2O, 2.5-9.0 mol % CaO, 0.0-3.0 mol % MgO, 0.0-3.0 mol % SrO, 0.0-3.0 mol % BaO, ~~and~~ 0.0-5.0 mol % MgO+SrO+BaO, and 0.0-0.45 mol % B_2O_3.

24. (currently amended) A glass substrate for an electronic display device, comprising:

a flat, transparent glass exhibiting a strain point of at least 640°C and a linear coefficient of thermal expansion of 80 to 95×10^{-7}/°C over a temperature range of 25 to 300°C, the glass comprising 59-66 mol % SiO_2, 14.5-18.0 mol % Al_2O_3, 8.5-12.0 mol % Na_2O, 2.5-6.5 mol % K_2O, 2.5-9.0 mol % CaO, 0.0-3.0 mol % MgO, 0.0-0.3 mol % SrO, 0.0-3.0 mol % BaO, ~~and~~ 0.0-5.0 mol % MgO+SrO+BaO, and 0.0-0.45 mol % B_2O_3.

25. (currently amended) A method of producing a glass panel for an electronic device, comprising:

melting a glass batch comprising 59-66 mol % SiO_2, ~~14.5~~15.0-18.0 mol % Al_2O_3, 8.5-12.0 mol % Na_2O, 2.5-6.5 mol % K_2O, 2.5-9.0 mol % CaO, 0.0-3.0 mol % MgO, 0.0-3.0 mol % SrO, 0.0-3.0 mol % BaO, ~~and~~ 0.0-5.0 mol % MgO+SrO+BaO, and 0.0-0.45 mol % B_2O_3; and

drawing a thin sheet of molten glass from the melt.

26. (original) The method of claim 25, wherein the glass sheet is drawn by the fusion draw process.